

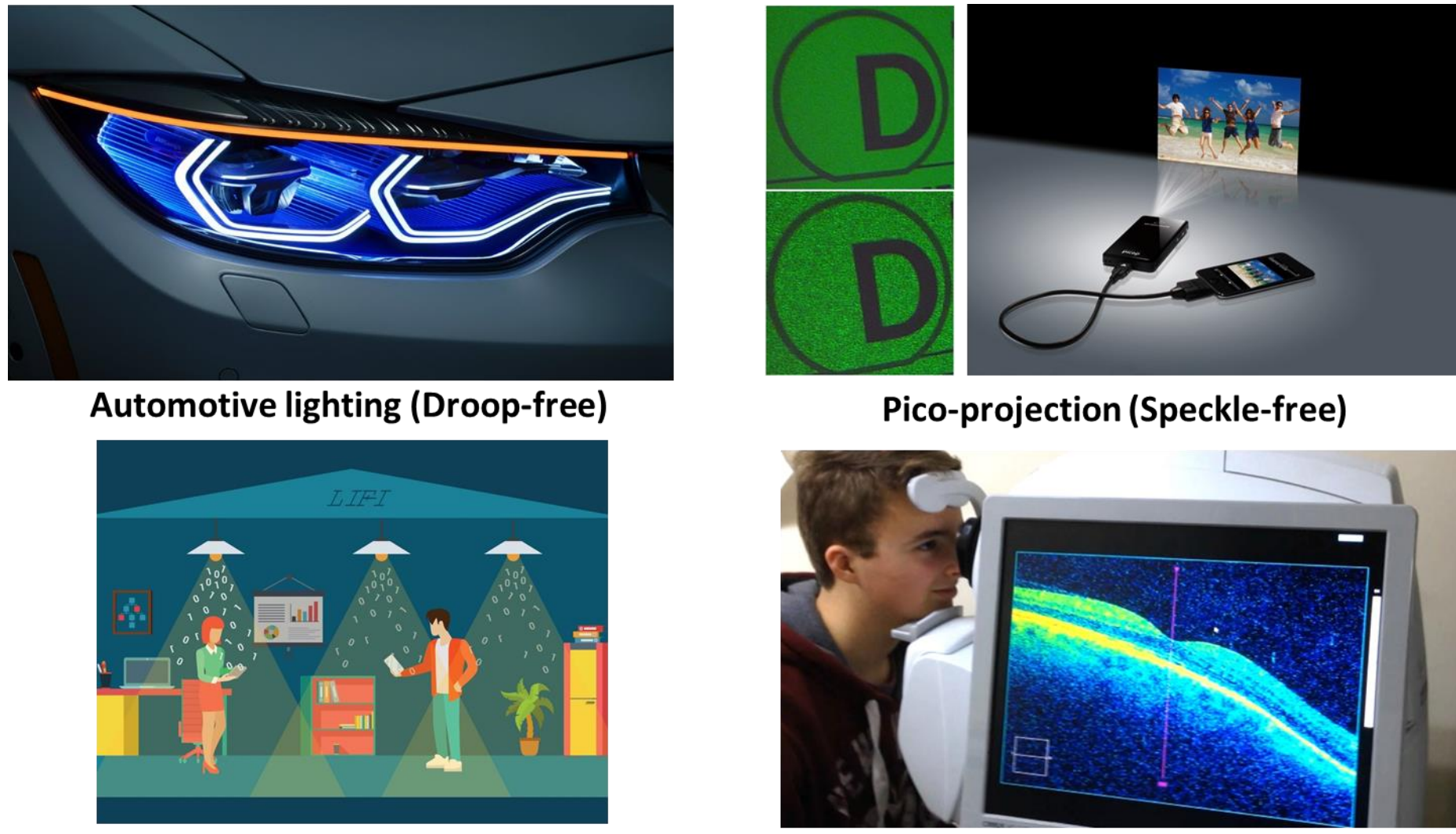


Investigation of Superluminescent Diodes for Smart-Lighting Systems

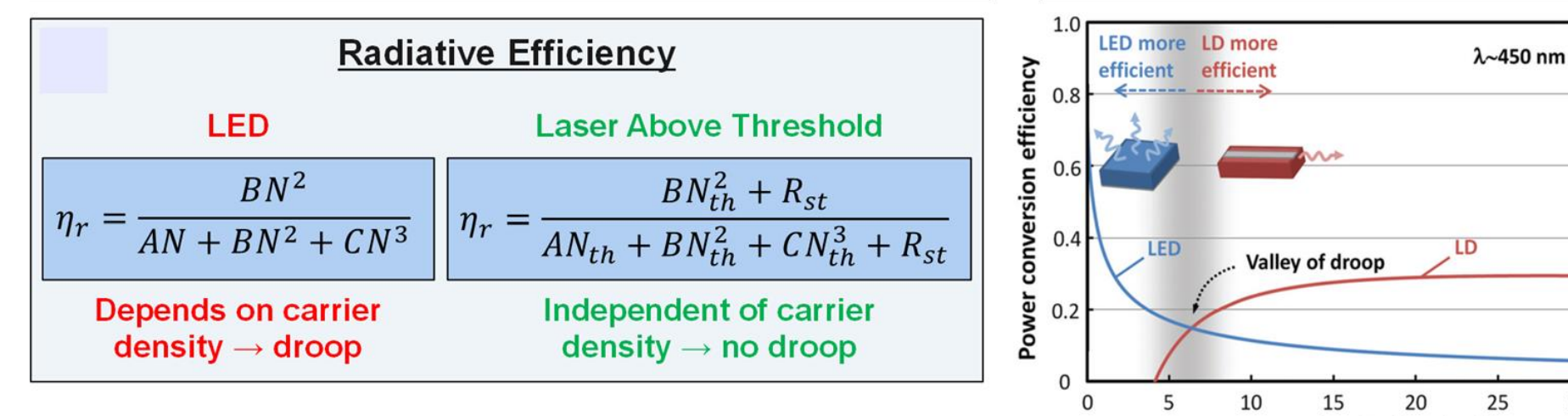
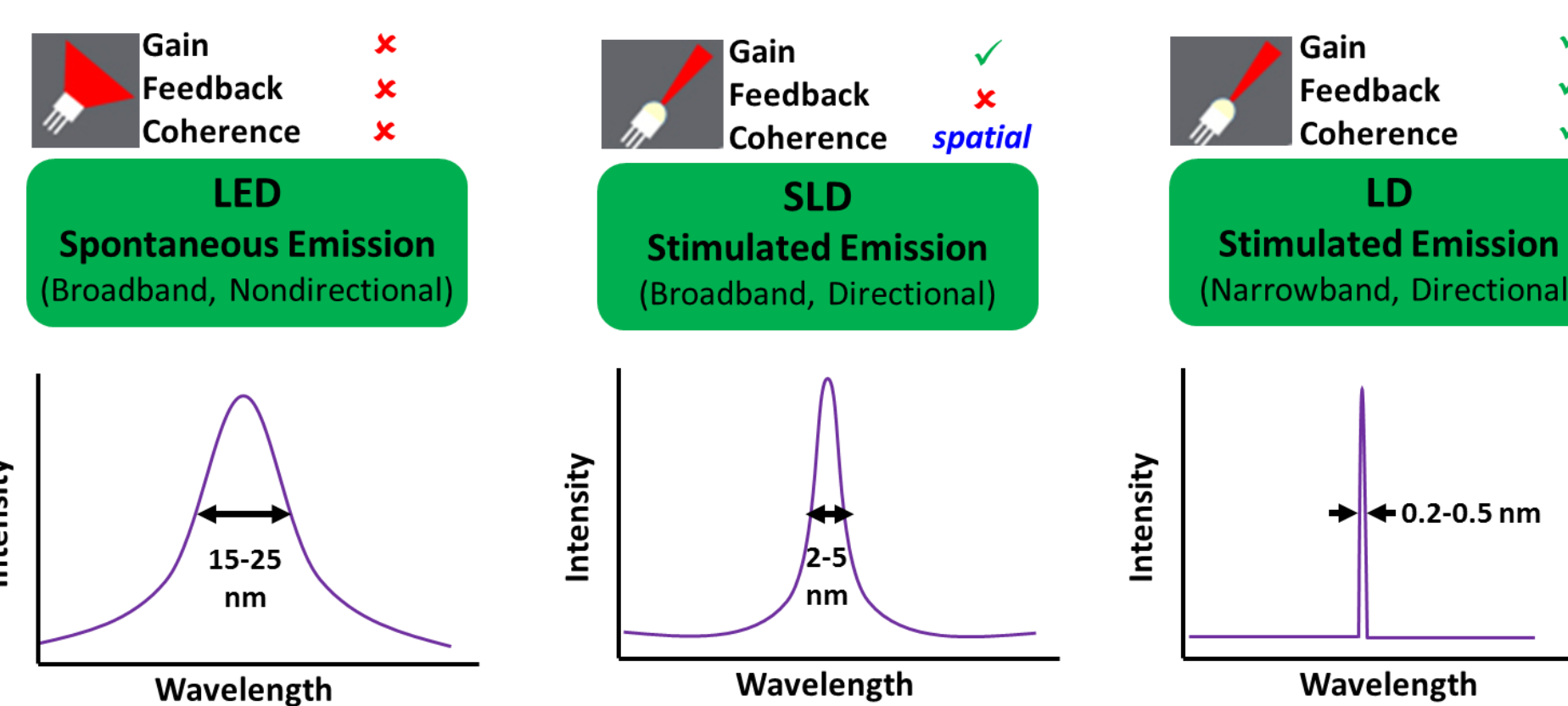
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Motivation

Applications of visible SLDs

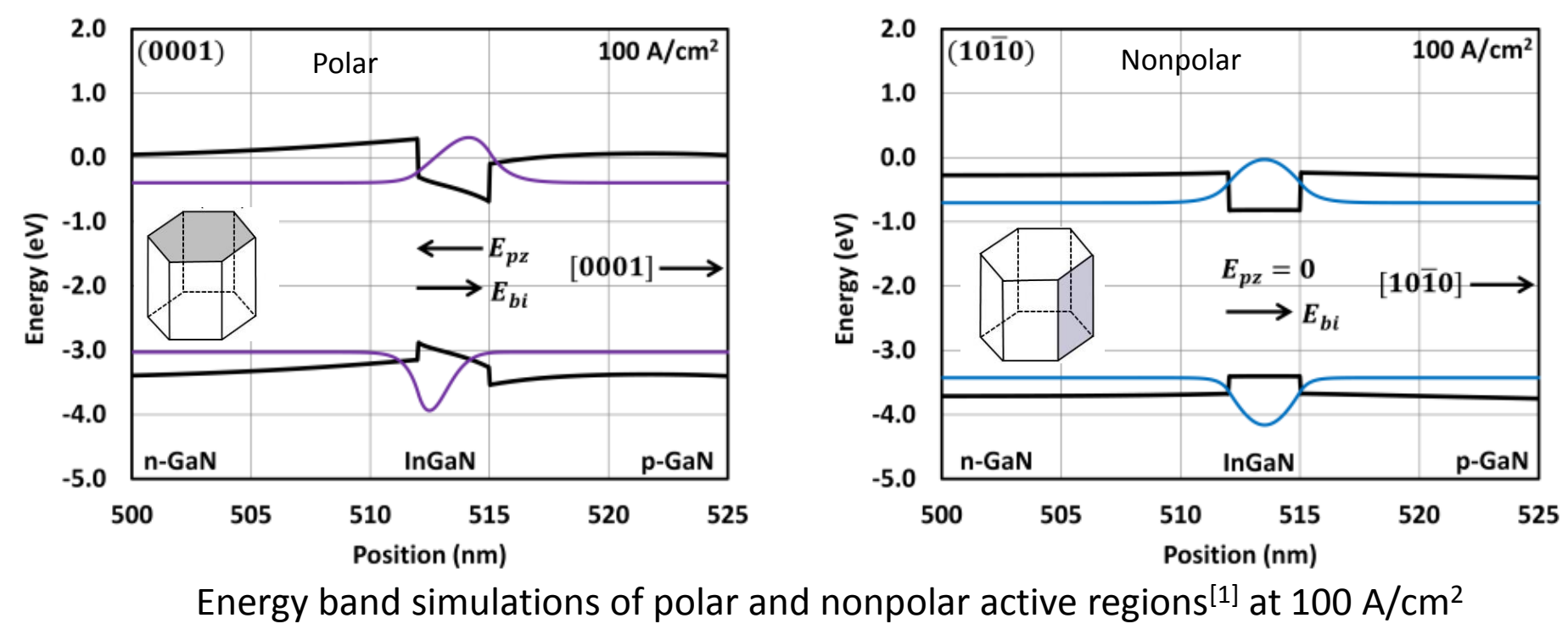


Advantages of SLDs over LEDs and Lasers

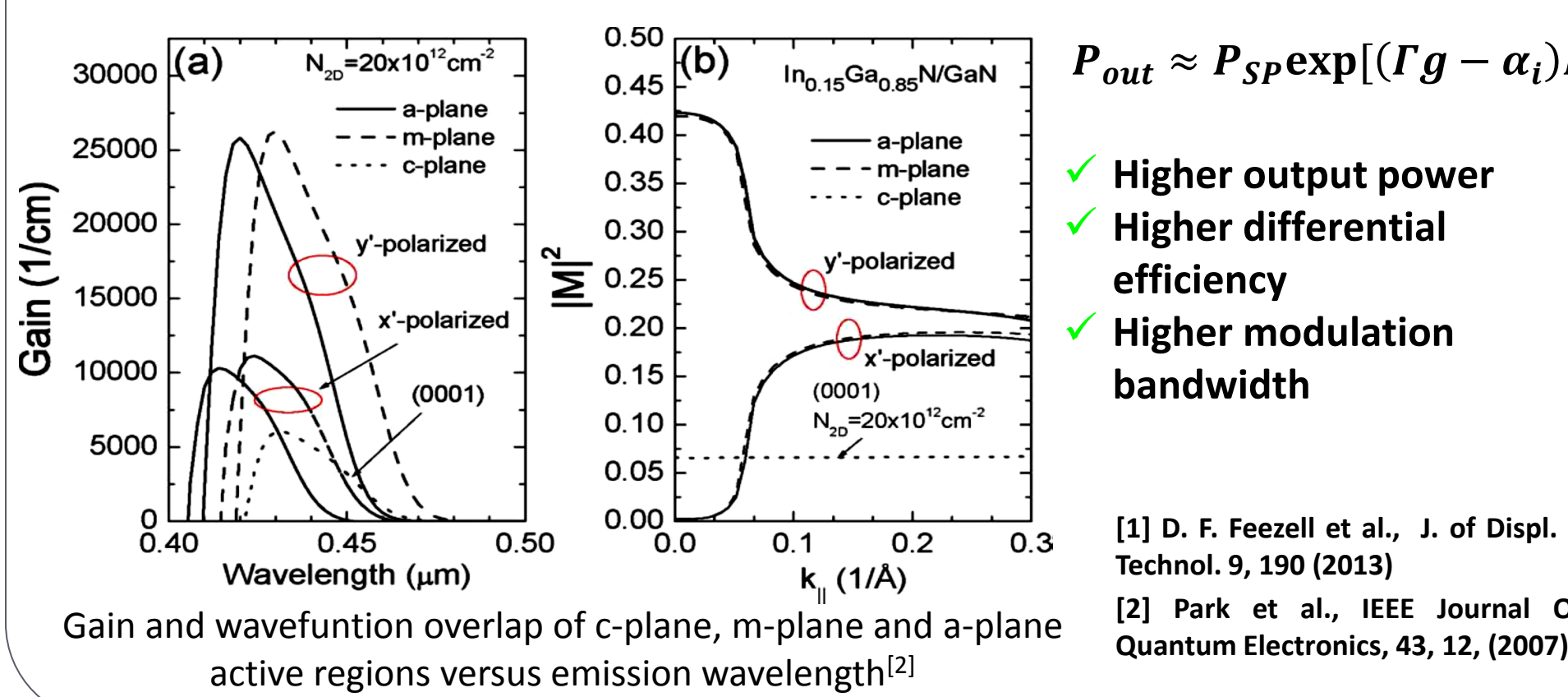


Comparison of the expression for IQE using the ABC model for spontaneous emission dominated devices (LEDs) and stimulated emission dominated devices (SLDs and laser diodes) [J. Wierer et al., (2013)]

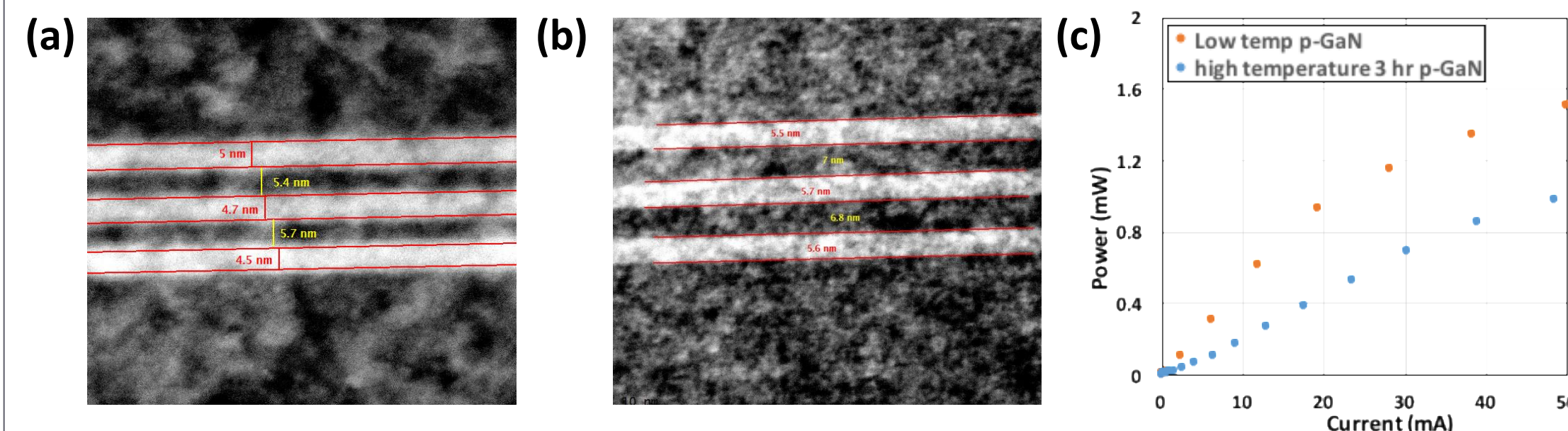
Advantages of nonpolar SLDs over c-plane SLDs



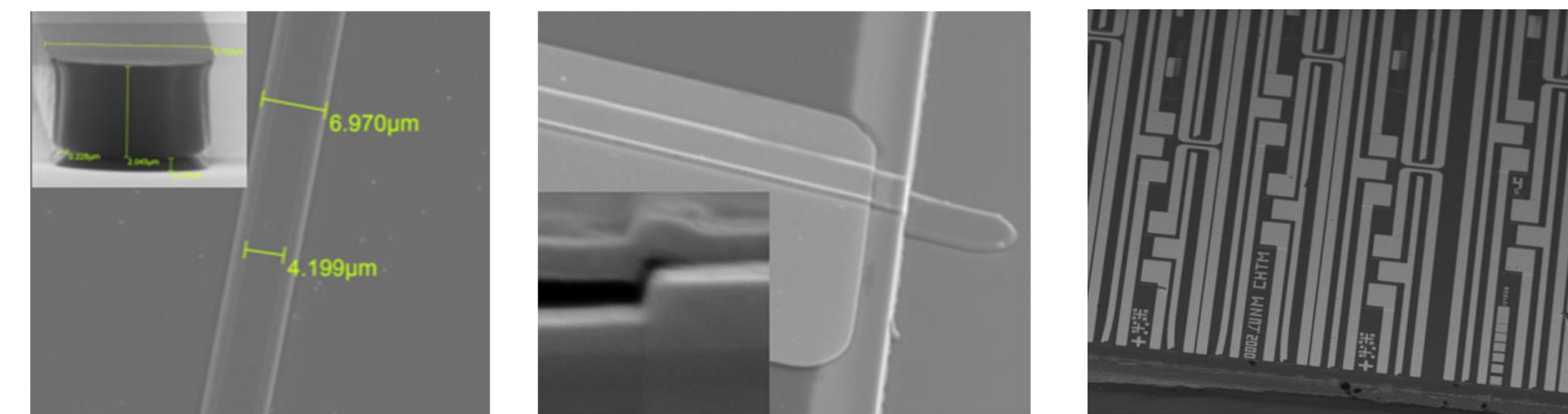
Higher gain in m-plane active regions



SLD Epitaxial Growth and Fabrication



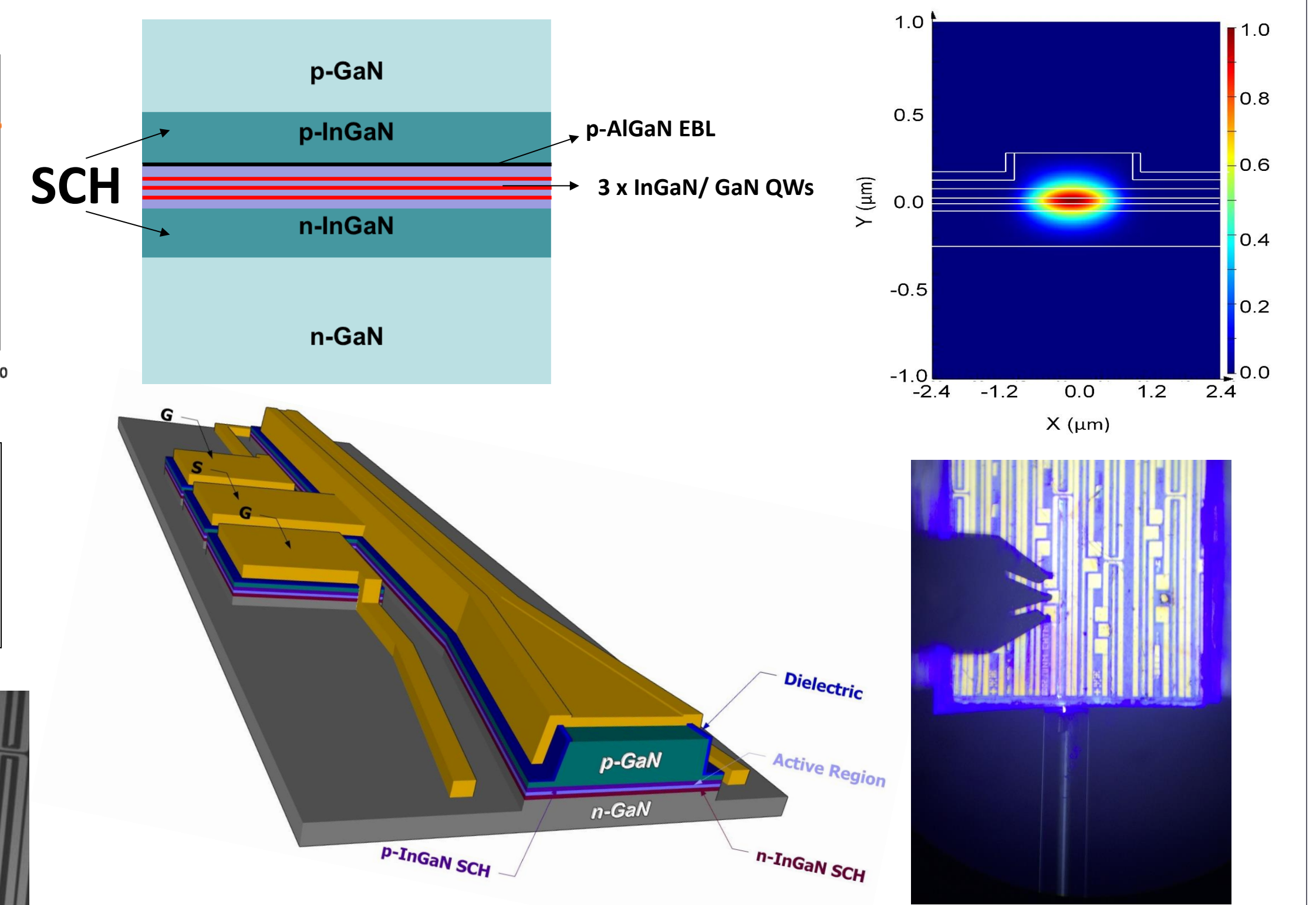
Comparison of active region area of planar *m*-plane LEDs with (a) 3 hr long p-GaN growth and (b) 45 min long p-GaN growth. The active region quality is improved considerably in the shorter p-GaN growth, confirmed by improved optical output power at a given current (c).



Self-aligned SiO₂ deposition. Inset shows the bilayer resist pattern used for achieving self-aligned dielectric

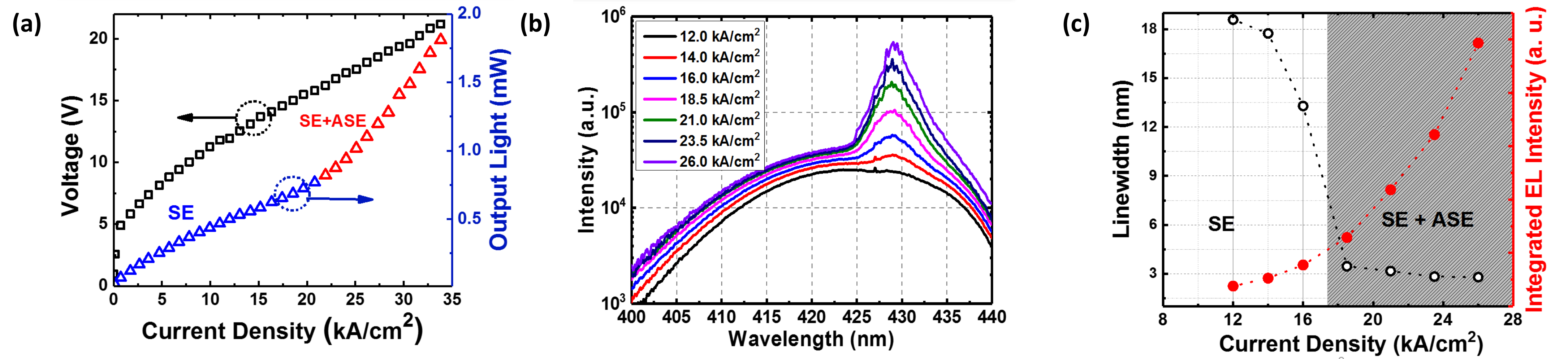
Facet-etch indicating good quality facets. Inset shows cross-section at the ridge

Fabricated SLD and laser arrays with pads for RF testing



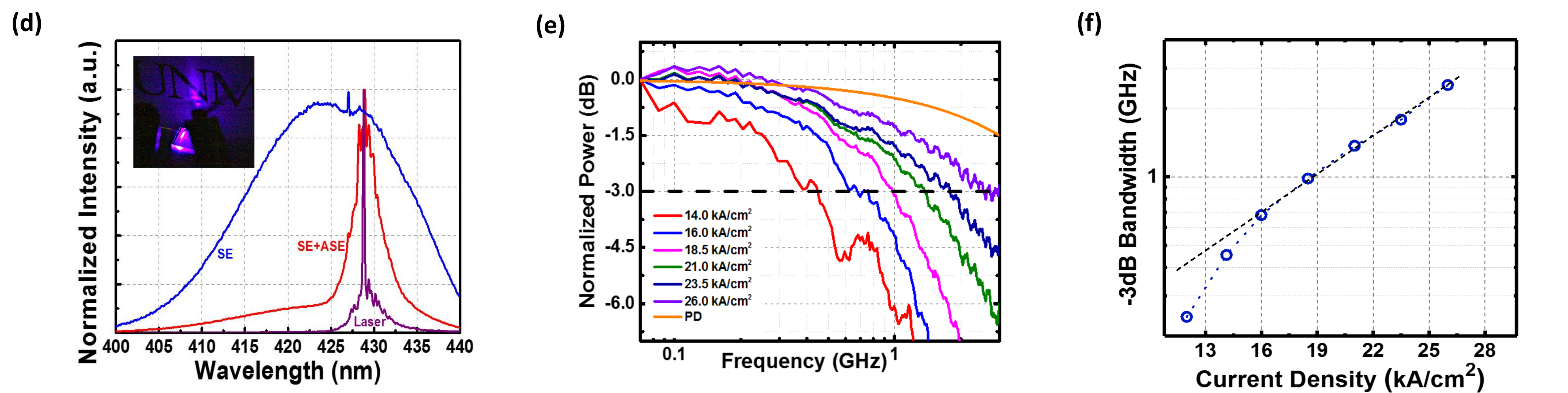
(a) Epitaxial layer structure of the SLD indicating the separately-confined heterostructure guiding, whose simulated mode profile using Lumerical (FDTD) is shown in (b). (c) Pictographic illustration of a fabricated tapered waveguide SLD (TSLD). (d) A TSLD under electrical operation

Electrical, Optical, and RF Characterization



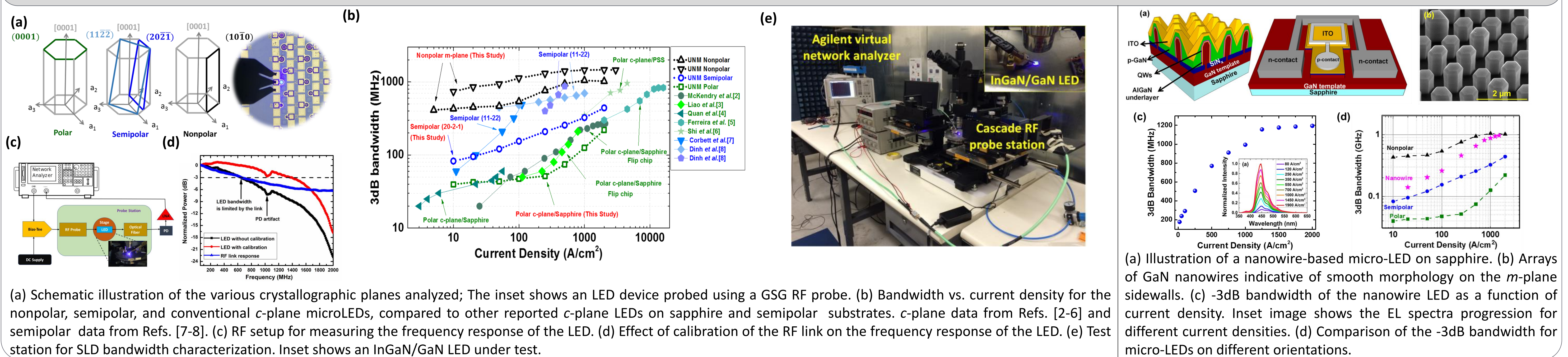
(a) L-J-V characteristics of TSLD. Spectral evolution is shown in (b). (c) Linewidth and total integrated power of the EL spectrum versus current density.

$$f_{3dB} \approx \frac{1.55}{2\pi} \sqrt{\frac{\Gamma^2 v_g^2 a(\alpha_m + \alpha_i) \beta (J - J_{tr})}{\alpha_m V}} \exp\left[\frac{(\Gamma \beta (J - J_{tr}) - \alpha_i) L}{2}\right]$$



(d) Normalized EL spectra of LED, SLD, and laser on the same chip. (e) Frequency response of the TSLD. The -3 dB RF modulation bandwidth is obtained and plotted versus current density in (f). The $\log(f_{3dB})$ goes linearly as a function of J in the superluminescence regime due to the exponential increase of the o/p power with J , evident from the above equation.

Record Modulation Bandwidth of Blue Micro-LEDs



(a) Schematic illustration of the various crystallographic planes analyzed; The inset shows an LED device probed using a GSG RF probe. (b) Bandwidth vs. current density for the nonpolar, semipolar, and conventional *c*-plane microLEDs, compared to other reported *c*-plane LEDs on sapphire and semipolar substrates. *c*-plane data from Refs. [2-6] and semipolar data from Refs. [7-8]. (c) RF setup for measuring the frequency response of the LED. (d) Effect of calibration of the RF link on the frequency response of the LED. (e) Test setup for SLD bandwidth characterization. Inset shows an InGaN/GaN LED under test.

(a) Illustration of a nanowire-based micro-LED on sapphire. (b) Arrays of GaN nanowires indicative of smooth morphology on the *m*-plane sidewalls. (c) -3dB bandwidth of the nanowire LED as a function of current density. Inset image shows the EL spectra progression for different current densities. (d) Comparison of the -3dB bandwidth for micro-LEDs on different orientations.